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430 Rec'd P/PTO 19 JUN 2000

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| In re Application of |) | | GIA |
|------------------------------------|---|-----------|----------|
| Tadahiro OHMI et al. |) | Group: | |
| Serial No.: |) | - | (4) |
| Filed: June 19, 2000 |) | Examiner: | |
| Title: SEMICONDUCTOR MANUFACTURING |) | | 10/3/100 |
| APPARATUS |) | | |

PRELIMINARY AMENDMENT

Hon. Commissioner of Patents and Trademarks Washington, D.C. 20231

Sir:

Applicant hereby submits the following Amendment.

IN THE SPECIFICATION

Page 1, line 12 please delete "Prior Art" and replace it with --Background of the Invention.--

Page 2, line 7 after "such" please insert --,-/.

Page 2, line 7 after "as" please insert --by-

Page 3, line 24 after "lifetime" please insert -- of the tool--.

Page 4, line 3 please delete "Disclosure of the Invention" and replace it with --SUMMARY OF THE INVENTION--.

Page 6, please insert before the first paragraph discussing Fig. 1 the following text:

The above-mentioned and other features and advantages of this invention, and the manner of attaining them, will become more apparent and the invention will be better understood by